

# Consideration on Fine Pitch WLCSP Application

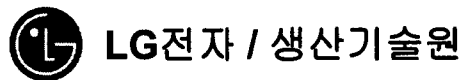
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(LG Electronics Inc./Korea)



# Considerations on fine pitch WLCSP application

2005. 9. 29

발표자 : 박종욱 책임연구원



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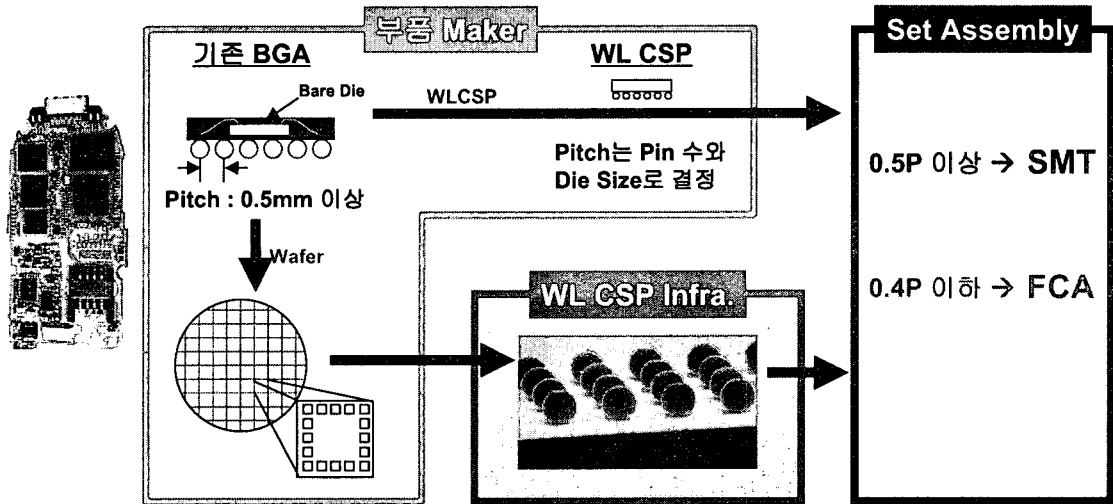
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# WLCSP Application Concept

## Fine Pitch WLCSP 적용 개요

- ▶ 관점
  - Set Maker
  - Mobile Product



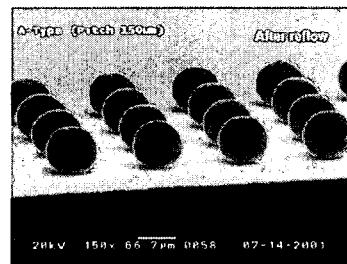
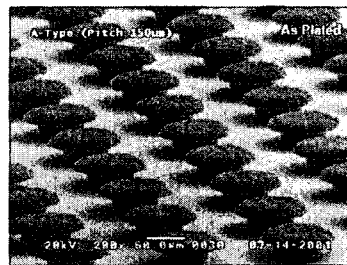
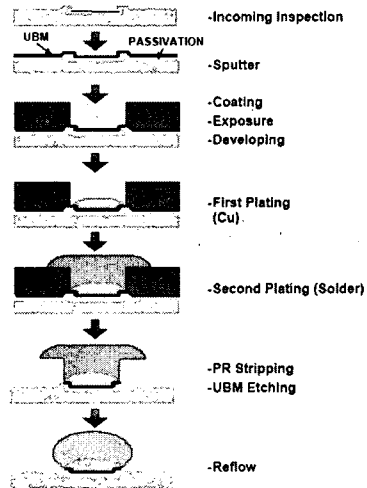
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# WLCSP Application Concept

## Solder Bumped Flip Chip

### Solder Bump - Process flow -

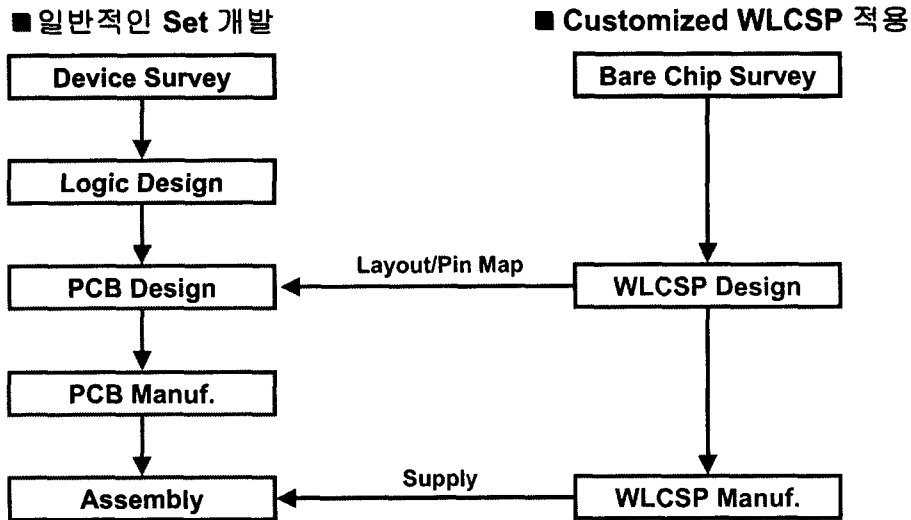


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## WLCSP Application Concept

### WLCSP 제품 적용 Procedure



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## WLCSP Application Concept

### WLCSP 적용 시 검토 항목

- |                     |   |
|---------------------|---|
| 1. Device Selection | <ul style="list-style-type: none"> <li>• Effect : Cost, Design Flexibility, Size, Thickness...</li> <li>• Wafer : In-house IC, Maker IC</li> <li>• Life Cycle</li> </ul>  |
| 2. Package Design   | <ul style="list-style-type: none"> <li>• Package Type, Pitch, Ball Array</li> <li>• Pattern Design : Critical Net(Analog/Digital), Signal Integrity</li> <li>• Mechanical Reliability</li> <li>• Production Capability</li> </ul> |
| 3. Packaging        | <ul style="list-style-type: none"> <li>• Infrastructure</li> <li>• Pb-free</li> <li>• Test Capability</li> </ul>  |
| 4. PCB              | <ul style="list-style-type: none"> <li>• Via (Laser, Laser Filled Via, Bump Via)</li> <li>• Minimum L/S, Via Dia. Clearance, Tolerance</li> <li>• Surface Treatment (Au, OSP)</li> </ul>  |
| 5. Production       | <ul style="list-style-type: none"> <li>• Line Facility</li> <li>• Inspection Method/Machine</li> <li>• Repair Method</li> <li>• N2 Soldering (500PPM under)</li> </ul>  |

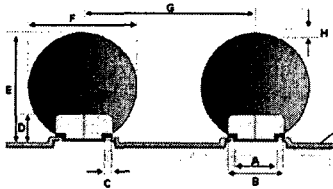
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## Fine Pitch FCA 공정 개발

### Test Chip Design

#### ■ Bump Spec.



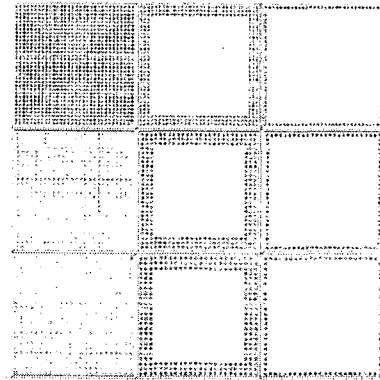
- Bumping Pitch : 150~200 $\mu\text{m}$
- Bump Height : 70~100 $\mu\text{m}$

#### ■ Test Die Layout

P:150 $\mu\text{m}$

P:180 $\mu\text{m}$

P:200 $\mu\text{m}$



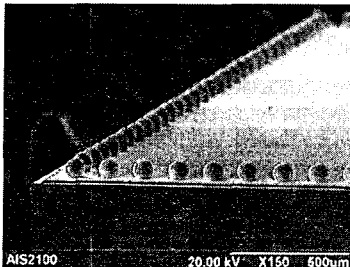
- Daisy Chain
- 1, 3-Peripheral, Full Grid

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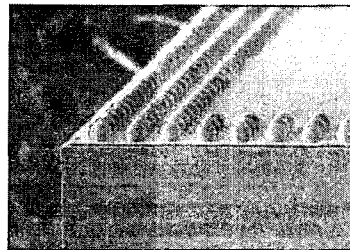


## Fine Pitch FCA 공정 개발

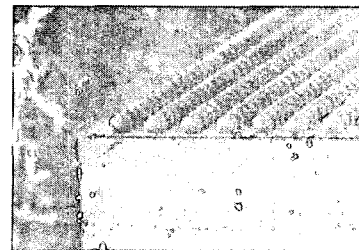
### Test Chip Manufacturing



**1- Peripheral**  
P: 150, 180, 200 $\mu\text{m}$



**3- Peripheral**  
P: 150, 180, 200 $\mu\text{m}$



**Full Grid**  
P: 150, 180, 200 $\mu\text{m}$

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# Fine Pitch FCA 공정 개발

## PCB Technology

|                            | LX-BUMP                               | B <sup>2</sup> T         | PALAP  | AGSP                         | SAVIA                                      | ALIVH  |
|----------------------------|---------------------------------------|--------------------------|--|------------------------------|--|--|
| <b>Lay-up Structure</b>    |                                       |                          |  |                              |  |  |
| <b>Substrate Material</b>  | FR-4, High Tg FR-4                    | High Tg FR-4             | Thermoplastic (C.P./PCEK)                            | Thermal Curable Resin        | High Tg FR-4, Unclad CCL                   | Aramid (Non woven)                               |
| <b>Via Formation</b>       | Plating Bump<br>Selective via plating | Piercing                 | Laser Drill(CO <sub>2</sub> ) + Silver Paste Filling | Plating + Etched Bump        | M/C drill or Laser Drill(CO <sub>2</sub> ) | Laser Drill(CO <sub>2</sub> ) + Cu Paste Filling |
| <b>Connection Method</b>   | Metallurgical Interconnection         | Ag Paste Interconnection | Metal paste Interconnection                          | Cu Plating Interconnection   | Conductive paste + Cu plating              | Conductive paste adhering                        |
| <b>CSP Pitch</b>           | 0.3mm                                 | 0.4mm                    | 0.4mm  | 0.4mm                        | 0.4mm                                      | 0.4mm  |
| <b>Stack Via</b>           | 0                                     | 0                        | 0  | 0                            | 0  | 0  |
| <b>AE IVH</b>              | 0                                     | 0                        | 0  | 0                            | 0  | 0  |
| <b>Participation Staff</b> | LG E                                  | Yoshida, Clove, Shimotoh | Dense, Aina, NEC, Noda Screen, Sowa, OKyama, Kyosha  | Dense, Clove, Matsya, Doosan | Samsung                                    | Matsushita, CMK                                  |
| <b>Present Step</b>        | Mass Production                       | Mass Production          | Development  | Mass Production              | Development                                | Mass Production                                  |

### Requirement

- Ball Pitch : 150 $\mu$ m
- Via Diameter : 150 $\mu$ m ↓
- Line/Spacing : 60/60 $\mu$ m ↓
- Stack Via
- Pad on Via
- Landless(Filled or Bump)

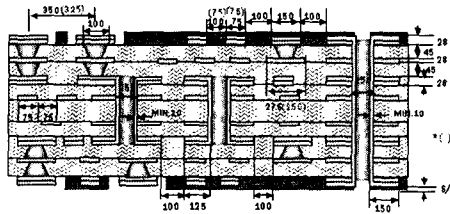
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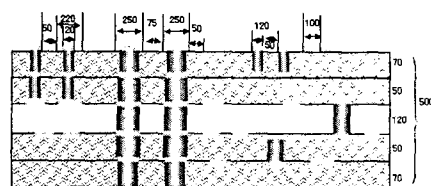
# Fine Pitch FCA 공정 개발

## 고집적 PCB DFM

■ Ball Pitch 0.3 이상  
→ Laser Via



■ Ball Pitch 0.3 이하  
→ Bump Via



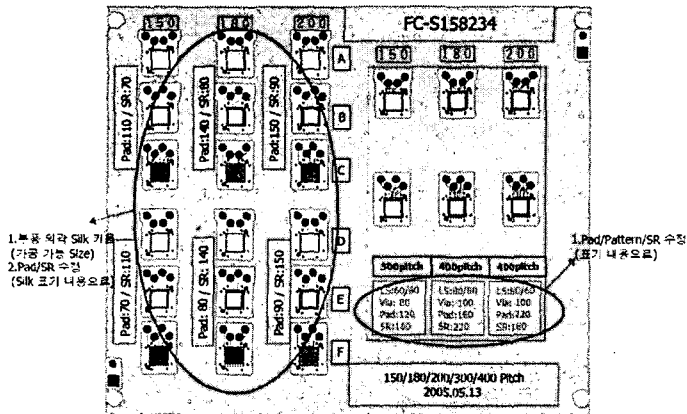
| IC Pitch   | 0.4           | 0.3           | 0.2           | 0.15          |
|------------|---------------|---------------|---------------|---------------|
| Via 구조     | Laser Bump    | Laser Bump    | Bump          | Bump          |
| Via Dia.   | 150 $\mu$ m   | 120 $\mu$ m   | 100 $\mu$ m   | 100 $\mu$ m   |
| Via Pitch  | 400 $\mu$ m   | 300 $\mu$ m   | 300 $\mu$ m   | 300 $\mu$ m   |
| Pad        | 190 $\mu$ m   | 140 $\mu$ m   | 90 $\mu$ m    | 70 $\mu$ m    |
| Line/Space | 80/80 $\mu$ m | 60/60 $\mu$ m | 50/50 $\mu$ m | 50/50 $\mu$ m |
| S/R 이력     | 50 $\mu$ m    | 30 $\mu$ m    | 20 $\mu$ m    | 10 $\mu$ m    |
| 표면 처리      | Au            | OSP           | OSP           | OSP           |

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# Fine Pitch FCA 공정 개발

## Test PCB Design



### Test Item

- Chip Interconnection
- PCB Delaminating
- Surface Insulation
- Joint Reliability

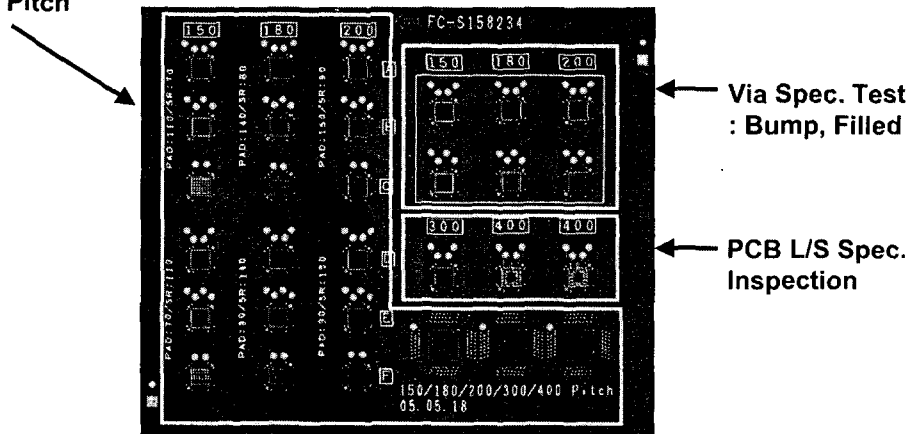
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# Fine Pitch FCA 공정 개발

## Test PCB Manufacturing

Chip Interconnection Test  
: 150~300/μm Pitch



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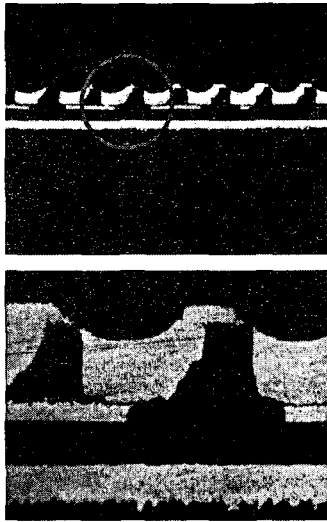




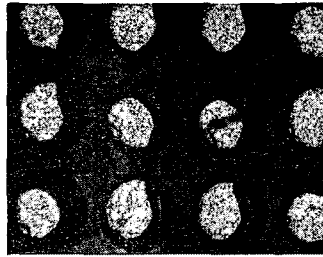
## Fine Pitch FCA 공정 개발

### Example : PCB Failure

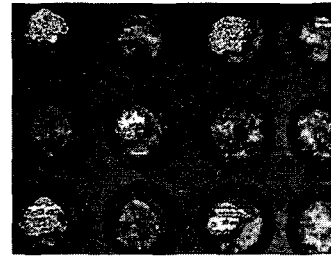
■ Delaminating



■ 위치 틀어짐



■ 도금 불량



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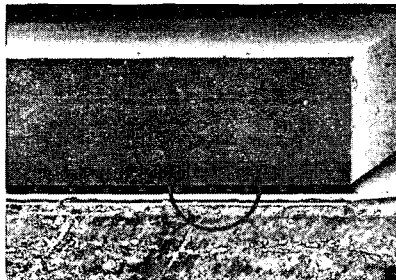
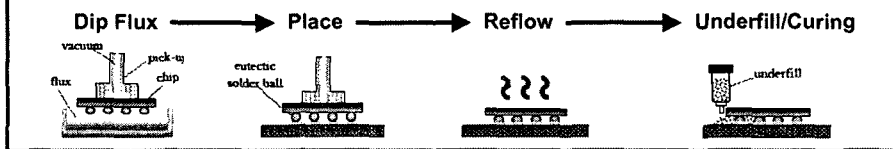


## Fine Pitch FCA 공정 개발

### Assembly Process

#### FCA(Flip Chip Attachment)

: 기존 생산 방식인 SMT를 그대로 유지하면서 Flip Chip 실장

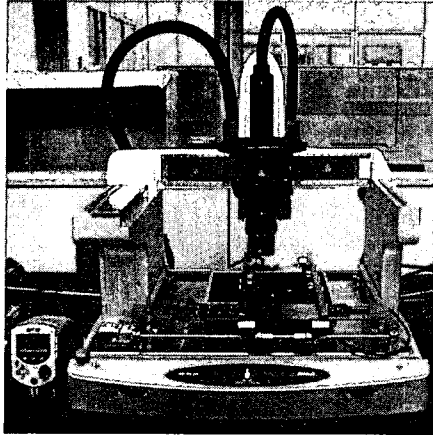


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# Fine Pitch FCA 공정 개발

## Flip Chip Assembly System



### ■ Test Machine

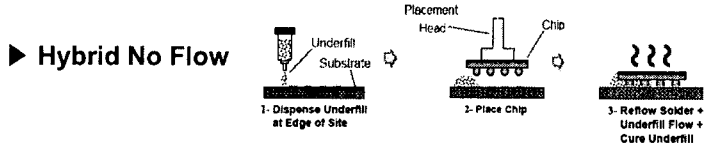
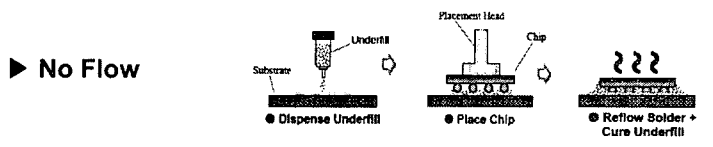
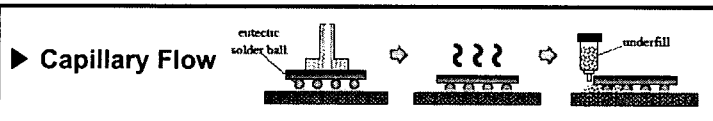
- ▶ Use
  - Assembly Process Test
  - Prototype
  - Production Condition Test
- ▶ Requirement
  - Minimum Pitch : 100 $\mu$ m
- ▶ Function
  - Chip Mount, N<sub>2</sub> Soldering
  - Chip Remove, Site-cleaning
  - Dispensing(Epoxy, Solder Paste)

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# Fine Pitch FCA 공정 개발

## Underfill Process



### ■ Requirement

| Properties                        | Desirable Values    |
|-----------------------------------|---------------------|
| Flow                              | > 0.5mm/s           |
| Adhesion                          | > 50MPa shear force |
| CTE                               | 18 ~ 30ppm/°C       |
| Elongation                        | > 1%                |
| Modulus                           | 5 ~ 8GPa            |
| Tg                                | > 130°C             |
| Stress after cure                 | < 10MPa             |
| Water pickup                      | < 1%                |
| Ionic Impurities                  | < 10ppm             |
| Thermal stability(1% weight loss) | > 260°C             |
| Curing time at 160°C              | < 0.5hr             |
| Volatility during cure            | < 1% weight loss    |
| Pot life at RT                    | > 8hr               |

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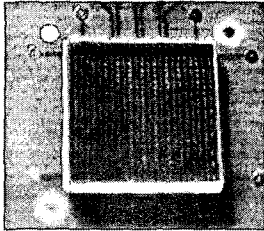


# Fine Pitch FCA 공정 개발

## Underfill / Material Selection

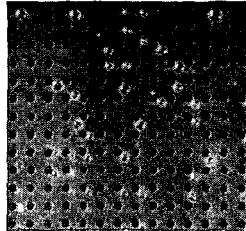
### ■ Flow Speed

• Glass Chip&Photo

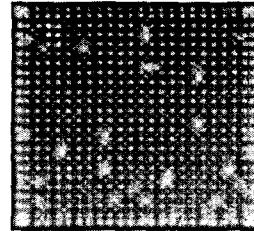


### ■ Void

• Glass Chip&Photo



• C-SAM



Example

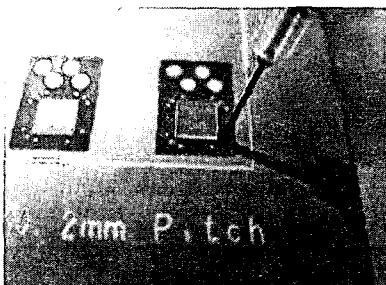
| Test Material | Flow Speed | Void | Repair |
|---------------|------------|------|--------|
| L             | ○          | ○    | △      |
| N             | ○          | ○    | x      |
| Z(W)          | ◎          | ○    | ○      |
| Z(B)          | ○          | ○    | ○      |

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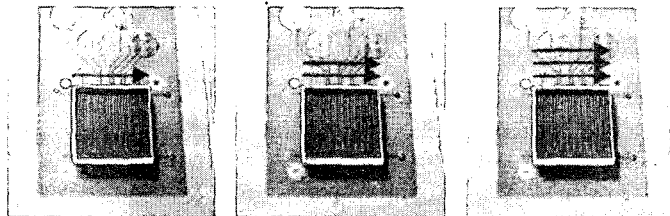


# Fine Pitch FCA 공정 개발

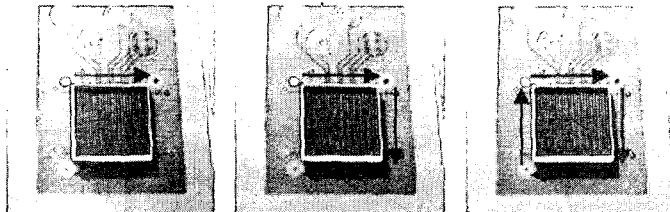
## Underfill / Dispensing Test



### ▶ 토출량 Test



### ▶ 토출 Pattern Test



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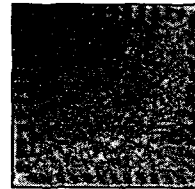
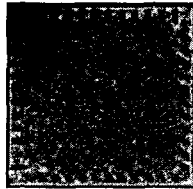


# Fine Pitch FCA 공정 개발

## Underfill / Substrate Temperature

■ Low Temperature  
: 70℃ 이하

■ High Temperature  
: 80℃ 이상

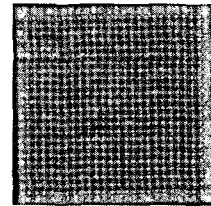
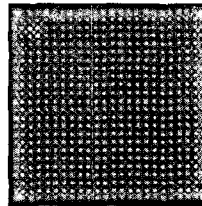
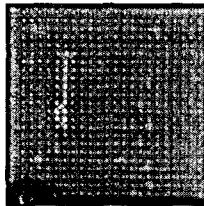
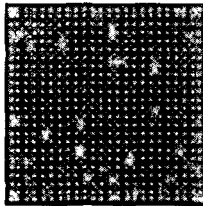


50℃

70℃

90℃

110℃



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# Fine Pitch FCA 공정 개발

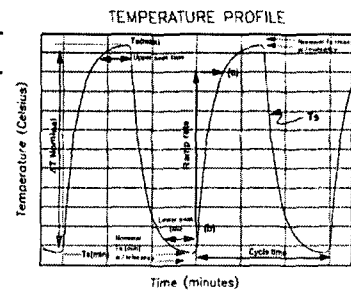
## Thermal Cycle Test

■ JEDEC Standard No.22-A104-B



Table 1 - Temperature cycling test conditions

| Test Condition* | Nominal Ts(min)(°C) with Tolerances | Nominal Ts(max)(°C) with Tolerances |
|-----------------|-------------------------------------|-------------------------------------|
| A               | -55(+0, -10)                        | +85(+10, -0)                        |
| B               | -55(+0, -10)                        | +125(+15, -0)                       |
| C               | -65(+0, -10)                        | +150(+15, -0)                       |
| G               | -40(+0, -10)                        | +125(+15, -0)                       |
| H               | -55(+0, -10)                        | +150(+15, -0)                       |
| I               | -40(+0, -10)                        | +115(+15, -0)                       |
| J               | -0(+0, -10)                         | +100(+15, -0)                       |
| K               | -0(+0, -10)                         | +125(+15, -0)                       |
| L               | -55(+0, -10)                        | +110(+15, -0)                       |
| M               | -40(+0, -10)                        | +150(+15, -0)                       |



(Example : Failure Chip Count)

| Cycles | Underfill |               | L | N | Z |
|--------|-----------|---------------|---|---|---|
|        | Underfill | Non-underfill |   |   |   |
| 100    | 0         | 0             | 0 | 0 | 0 |
| 200    | 1         | 1             | 0 | 0 | 0 |
| 300    | 6         | 10            | 0 | 0 | 0 |
| 400    | 4         | All           | 0 | 0 | 0 |

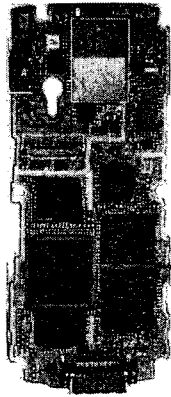
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# Mobile Phone 적용 사례

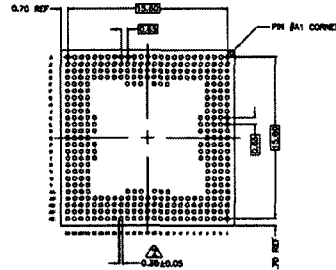
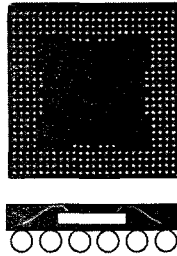
## Target IC Selection

### Mobile Phone



### 0.65mm Pitch, 360pin BGA

- Package Size : 17x17mm<sup>2</sup>
- Die Size : 7.7x7.7mm<sup>2</sup>



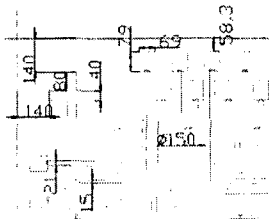
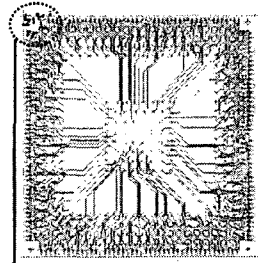
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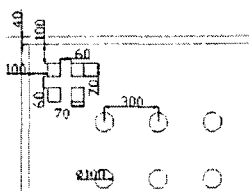
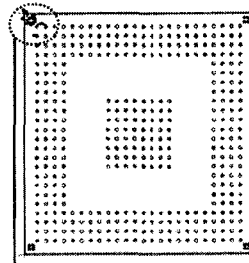
# Mobile Phone 적용 사례

## WLCSP Design

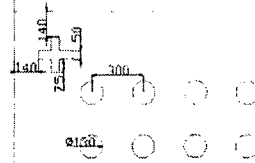
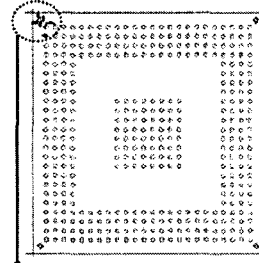
### Pattern Layer



### Passivation Layer



### Barrier Metal Layer



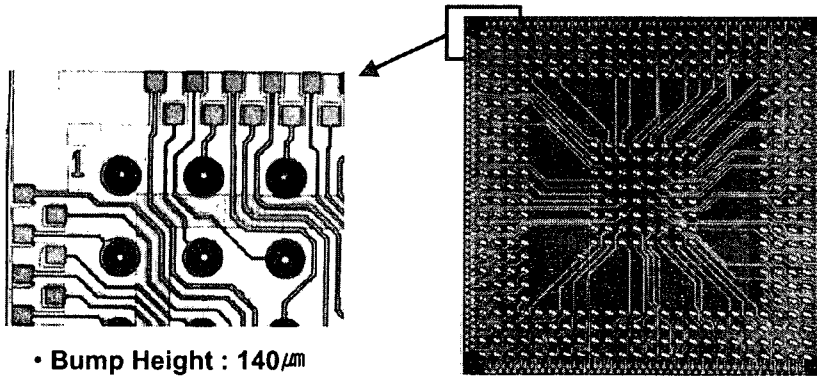
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## Mobile Phone 적용 사례

### WLCSP Manufacturing

■ 0.3mm Pitch, 360pin WLCSP



• Bump Height : 140 $\mu$ m

• Size : 7.7x7.7mm<sup>2</sup>

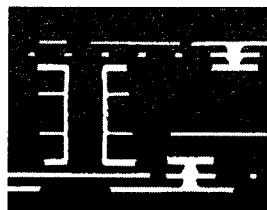
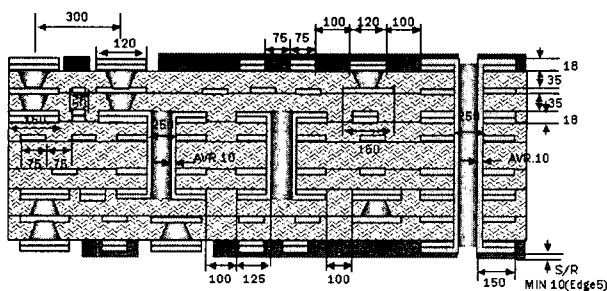
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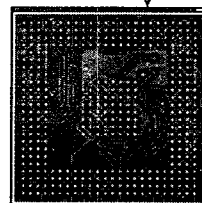
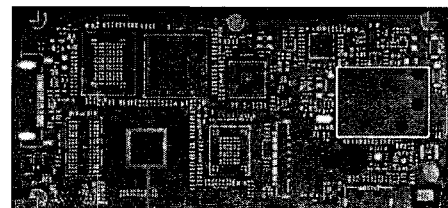
## Mobile Phone 적용 사례

### Main PCB Design

■ PCB DFM



■ CAD Design



- Laser Filled Via
- L/S : 60/60 $\mu$ m
- 표면처리 : OSP

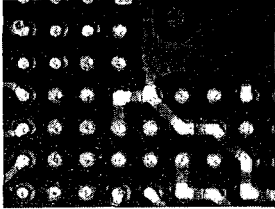
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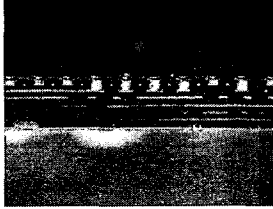
## Mobile Phone 적용 사례

### PCB Manufacturing

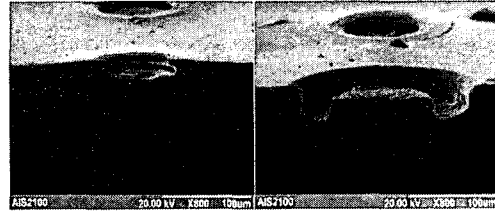
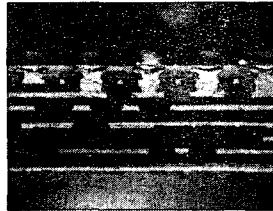
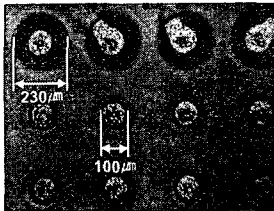
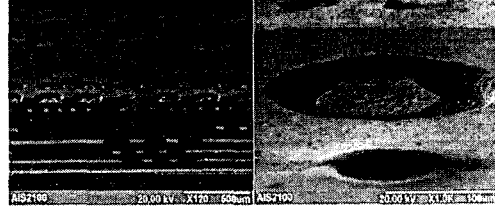
■ Top View



■ Cross Section



■ SEM

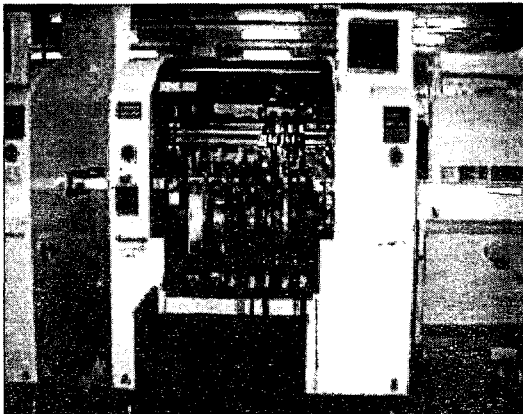


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## Mobile Phone 적용 사례

### Assembly Line



■ Mass Production Machine

▶ Use

- Sample / Mass Production

▶ Requirement

- Minimum Pitch : 200 μm

▶ Function

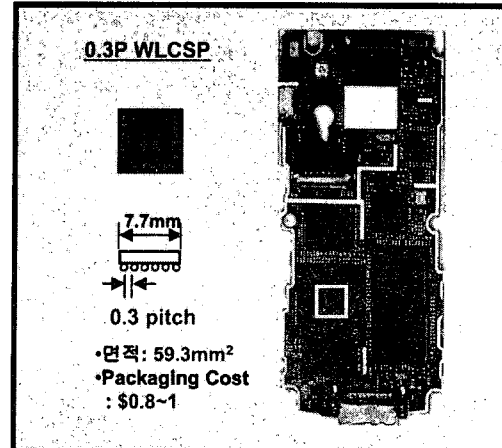
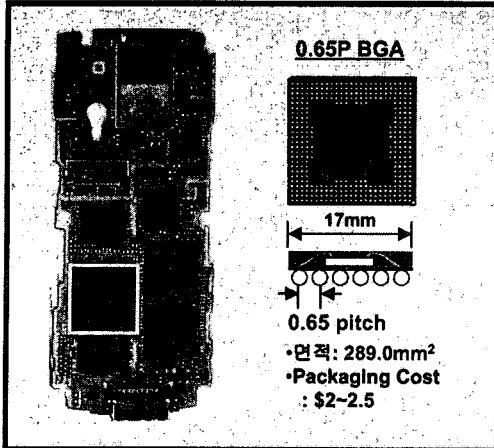
- Flux Dipping & Chip Mount Module Attached
- General Chip Mount

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## Mobile Phone 적용 사례

### PCB Assembly



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## Summary

- 기존 단말기에 Fine Pitch (0.3mm) WLCSP를 개발/적용해 봄으로써 SMT 조립 한계로 인식되고 있는 Pitch인 0.4mm이하의 접속 기술을 검증함.
- Set Maker 입장에서 Fine Pitch를 가진 Customized Package를 적용할 경우, Design 단계에서부터 부품, 기판, 조립공법, Infrastructure등을 동시에 검토해야 함.
- 이동단말의 소형화/박형화 경쟁이 가속화 되는 가운데 Package Pitch만을 고려해 볼 때, 2006년에는 0.4mm Pitch를 가진 BGA의 적용이 확대 될 것으로 예상되며 일부 제품에서 0.3mm Pitch Package의 적용도 예상됨.

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